## Integrated sputter target assembly

Publication number: CN1107523 Publication date:

1995-08-30

Inventor:

DEMARAY RICHARD ERNEST (US); HERRERA MANUEL J (US); BERKSTRESSER DAVID E (US)

Applicant:

APPLIED MATERIALS INC (US)

Classification: - international:

C23C14/34; C23C14/35; C23C14/56; H01J37/32; H01J37/34; H01L21/203; H01L21/31; C23C14/34;

C23C14/35; C23C14/56; H01J37/32; H01L21/02; (IPC1-7): C23C14/34

- European:

C23C14/34B; C23C14/56D; H01J37/32D; H01J37/34B

Application number: CN19941018712 19941121

Priority number(s): US19930157763 19931124; US19940236715 19940429

Also published as:

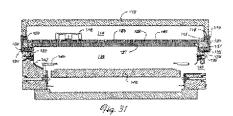
EP0654543 (A2) US5565071 (A1) JP7197248 (A) EP0654543 (A3)

CN1058998C (C)

Report a data error here

Abstract not available for CN1107523 Abstract of corresponding document: EP0654543

A target plate assembly (77; 124; 213) completely covers and seals against a top opening of a sputtering processing chamber (69; 138). Cooling liquid connections are provided only from the perimeter of the target assembly (77; 114; 213). When a top vacuum chamber (109; 114) seals the side opposite the pressure chamber (69; 138), the pressure on both sides of the target assembly (77; 114; 213) is nearly equalized. Large thin target assemblies, such as large flat plates used for flat panel displays can be sputtered effectively and uniformly without adverse sputtering effects due to target deflection or cooling deficiencies. A target (79; 127; 181), target backing plate (80; 128; 171), and cover plate (95; 125 126; 197) may form the target plate assembly (77; 124; 213). The sputtering target assembly (77; 124; 213) includes an integral cooling passage. A series of grooves (70; 96; 149; 172) are constructed in either the target backing plate (80; 128; 171) or the target backing cooling cover plate (95; 125; 126; 197), which are then securely bonded to one another. The sputtering target (79; 127;181) can be a single monolith with a target backing plate (80; 128; 171) or can be securely attached to the target backing plate (80; 128; 171) by one of any number of conventional bonding methods. Tantalum to titanium, titanium to titanium and aluminum to titanium, diffusion bonding can be used. The energized target assembly is protected from adjacent components by overlapping insulators (117, 134; 210, 216, 133) to prevent accidents and isolate the target assembly from other components. An electrical connection to the target assembly (77; 124; 213) remains unconnected until a vacuum is produced in the top chamber (109; 114).



Data supplied from the esp@cenet database - Worldwide

## [19]中华人民共和国专利局



## [12] 发明专利申请公开说明书

[21]申请号 94118712.8

[51]Int.Cl<sup>6</sup>
C23C 14/34

|43|公开日 1995年8月30日

[22]申请日 94.11.21

[30]优先权

[32]93.11.24|33|US[31]157,763 [32]94.4.29 [33|US[31]236,715

[71]申请人 应用材料有限公司

地址 美国加利福尼亚州

[72]发明人 理査第・E・毎马雷

曼纽尔・J・蘇當拉

大卫·E·伯特斯特莱塞

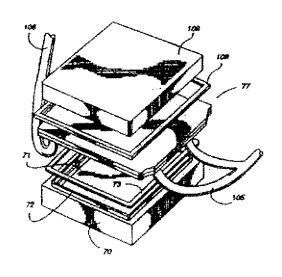
[74]专利代理机构 中国国际贸易促进委员会专利商标事务所 代理人 李 級

说明书页数:

附图页数:

## [54]发明名称 集成式激射靶组合件 [57]接要

靶组合件由靶材、靶支托板及蓝板构成,它含有一整体式的冷却通道。在支托板或盖板上事先开有若干沟槽,再格之牢固粘合,冷却液接头又只布置在其周界处,从而消除了该液漏入并污染处理室及工作的危险。组合件的下方封住了处理室,上方封住了内故扫动磁铁的并抽成真空的顶室,由于该件两侧压强已大致相同, 棋使其形大而薄(铍平板显示器时需用), 镀层仍能均匀, 靶材利用率亦高,消除了因靶材弯沉或冷却不足而带来的不利影响。



(BJ)第 1456 号